

**Amendments to the Specification:**

Please amend the specification as follows:

Please replace paragraph [0001] on page 1 of the present Specification with the following rewritten paragraph:

[0001] The present application is ~~a continuation in part application of related to~~ U.S. Application Serial No. [[\_\_\_\_\_]] 10/341,863, filed on [[\_\_\_\_\_]] January 14, 2003 by Ngo et al., entitled “Shallow Trench Isolation For Strained Silicon Process” (Attorney Docket No. 39153/639/H0963) and assigned to the Assignee of the present application.